

United States Patent and Trademark Office

UNITED STATES DEPARTMENT OF COMMERCE United States Patent and Trademark Office Address: COMMISSIONER FOR PATENTS P.O. Box 1450 Alexandria, Virginia 22313-1450 www.uspto.gov

APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.	
10/808,068	03/24/2004	James McKinnell	200310815-1	5360	
22879	7590 11/15/2005		EXAM	INER	
HEWLETT I	PACKARD COMPA	HA, NATHAN W			
P O BOX 272400, 3404 E. HARMONY ROAD					
INTELLECTUAL PROPERTY ADMINISTRATION			ART UNIT	PAPER NUMBER	
FORT COLLINS, CO 80527-2400			2814		

DATE MAILED: 11/15/2005

Please find below and/or attached an Office communication concerning this application or proceeding.

		\sim			
	Application No.	Applicant(s)			
	10/808,068	MCKINNELL ET AL.			
Office Action Summary	Examiner	Art Unit			
	Nathan W. Ha	2814			
The MAILING DATE of this communication a Period for Reply	ppears on the cover sheet wi	th the correspondence address			
A SHORTENED STATUTORY PERIOD FOR REF WHICHEVER IS LONGER, FROM THE MAILING - Extensions of time may be available under the provisions of 37 CFR after SIX (6) MONTHS from the mailing date of this communication. - If NO period for reply is specified above, the maximum statutory perions. - Failure to reply within the set or extended period for reply will, by state that the period for reply will, by state that the management of the management of the management patent term adjustment. See 37 CFR 1.704(b).	DATE OF THIS COMMUNIC 1.136(a). In no event, however, may a re- od will apply and will expire SIX (6) MON tute, cause the application to become AB	CATION. eply be timely filed THS from the mailing date of this communication. ANDONED (35 U.S.C. § 133).			
Status					
1) Responsive to communication(s) filed on 24	March 2004.				
2a) This action is FINAL . 2b) TI	This action is FINAL . 2b) This action is non-final.				
	Since this application is in condition for allowance except for formal matters, prosecution as to the merits is				
closed in accordance with the practice unde	r <i>Ex parte Quayle</i> , 1935 C.D	. 11, 453 O.G. 213.			
Disposition of Claims					
4)⊠ Claim(s) <u>1-46</u> is/are pending in the application	on.				
4a) Of the above claim(s) is/are withd	rawn from consideration.				
5) Claim(s) is/are allowed.					
6) Claim(s) is/are rejected.					
7) Claim(s) is/are objected to.					
8)⊠ Claim(s) <u>1-46</u> are subject to restriction and/o	or election requirement.				
Application Papers					
9)☐ The specification is objected to by the Exami	iner.				
10)☐ The drawing(s) filed on is/are: a)☐ a	ccepted or b) ☐ objected to	by the Examiner.			
Applicant may not request that any objection to the					
Replacement drawing sheet(s) including the corr					
11) ☐ The oath or declaration is objected to by the	Examiner. Note the attached	I Office Action or form PTO-152.			
Priority under 35 U.S.C. § 119					
12) ☐ Acknowledgment is made of a claim for forei a) ☐ All b) ☐ Some * c) ☐ None of:	gn priority under 35 U.S.C. §	119(a)-(d) or (f).			
 Certified copies of the priority docume 	ents have been received.				
2. Certified copies of the priority docume					
3. Copies of the certified copies of the pr		received in this National Stage			
application from the International Bure		and the desired			
* See the attached detailed Office action for a l	ist of the centiled copies not	received.			
Attachment(s)					
1) Notice of References Cited (PTO-892)	4) 🔲 Interview S	Summary (PTO-413)			
2) Notice of Draftsperson's Patent Drawing Review (PTO-948)	Paper No(s	s)/Mail Date nformal Patent Application (PTO-152)			
Information Disclosure Statement(s) (PTO-1449 or PTO/SB/0 Paper No(s)/Mail Date	6) Other:				

Application/Control Number: 10/808,068 Page 2

Art Unit: 2814

DETAILED ACTION

Election/Restrictions

- 1. Restriction to one of the following inventions is required under 35 U.S.C. 121:
 - I. Claims 1-17, 34-35, and 37-39 are drawn to a semiconductor device, classified in class 257, subclass 758.
 - II. Claims 18-33, 36, and 40-46 are drawn to a method of making a semiconductor device, classified in class 438, subclass 118.

The inventions are distinct, each from the other because of the following reasons: Inventions II and I are related as process of making and product made. The inventions are distinct if either or both of the following can be shown: (1) that the process as claimed can be used to make other and materially different product or (2) that the product as claimed can be made by another and materially different process (MPEP § 806.05(f)). In the instant case unpatentability of the group I invention would not necessarily imply unpatentability of the group II invention, since the device of the group I invention could be made by processes materially different from those of the group II invention. For example, instead of depositing the traces on the substrate, as set forth in claim 18, the process may be carried out by printing.

2. Because these inventions are distinct for the reasons given above and have acquired a separate status in the art as shown by their different classification, restriction for examination purposes as indicated is proper.

Art Unit: 2814

Applicant is advised that the reply to this requirement to be complete must include an election of the invention to be examined even though the requirement be traversed (37 CFR 1.143).

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Nathan W. Ha whose telephone number is (571) 272-1707. The examiner can normally be reached on M-TH 8:00-7:00(EST).

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Wael Fahmy can be reached on (571) 272-1705. The fax phone numbers for the organization where this application or proceeding is assigned are (703) 872-9306 for regular communications and (703) 872-9306 for After Final communications.

Any inquiry of a general nature or relating to the status of this application or proceeding should be directed to the receptionist whose telephone number is (703) 308-0956.

Nathan Ha

November 4, 2005

John will